INTERNATIONAL SEARCH REPORT

International application No.
PCT/JP03/11656

A. CLASSIFICATION OF SUBJECT MATTER Int.Cl ⁷ C01B33/035					
According to International Patent Classification (IPC) or to both national classification and IPC					
B. FIELDS SEARCHED					
Minimum documentation searched (classification system followed by classification symbols) Int.Cl ⁷ C01B33/00					
Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched Jitsuyo Shinan Koho 1922-1996 Toroku Jitsuyo Shinan Koho 1994-2003 Kokai Jitsuyo Shinan Koho 1971-2003 Jitsuyo Shinan Toroku Koho 1996-2003					
Electronic data base consulted during the international search (name of data base and, where practicable, search terms used) JSTPlus (JOIS)					
C. DOCUMENTS CONSIDERED TO BE RELEVANT					
Category* Citation of document, with indication, where appropriate, of the relevant passages Relevant to claim	No.				
E,X JP 2003-242016 A (Takayuki SHIMAMUNE), 1-9 03 December, 2003 (03.12.03), Claims; page 3, right column, lines 49 to 50 (Family: none)					
P,X JP 2003-95633 A (Yutaka KAMAIKE), 03 April, 2003 (03.04.03), Claims (Family: none)	-				
X D.A. SEIFERT, PILOT-SCALE DEVELOPMENT OF THE ZINC REDUCTION PROCESS FOR PRODUCTION OF HIGH- PURITY SILICON, AICHE SIMPOSIUM SERIES, 1982, No.216, Vol.78, pages 104 to 115 1-5,7,30-3 37-38,69 6,8-29,36 39-68	•				
Further documents are listed in the continuation of Box C. See patent family annex.					
* Special categories of cited documents: "T" later document published after the international filing date on priority date and not in conflict with the application but cited understand the principle or theory underlying the invention	l to				
"E" earlier document but published on or after the international filing "X" document of particular relevance; the claimed invention can considered novel or cannot be considered to involve an invention.	ot be tive				
"L" document which may throw doubts on priority claim(s) or which is step when the document is taken alone cited to establish the publication date of another citation or other "Y" document of particular relevance; the claimed invention can	ot be				
special reason (as specified) considered to involve an inventive step when the document is combined with one or more other such documents, such	s .				
means combination being obvious to a person skilled in the art document published prior to the international filing date but later "&" document member of the same patent family than the priority date claimed					
Date of the actual completion of the international search 16 December, 2003 (16.12.03) Date of mailing of the international search report 13 January, 2004 (13.01.04)					
Name and mailing address of the ISA/ Japanese Patent Office Authorized officer	Authorized officer				
Facsimile No. Telephone No.					

INTERNATIONAL SEARCH REPORT

International application No.
PCT/JP03/11656

Box I Observations where certain claims were found unsearchable (Continuation of item 2 of first sheet)					
This international search report has not been established in respect of certain claims under Article 17(2)(a) for the following reasons:					
1. Claims Nos.: because they relate to subject matter not required to be searched by this Authority, namely:					
 Claims Nos.: because they relate to parts of the international application that do not comply with the prescribed requirements to such an extent that no meaningful international search can be carried out, specifically: 					
3. Claims Nos.: because they are dependent claims and are not drafted in accordance with the second and third sentences of Rule 6.4(a).					
Box II Observations where unity of invention is lacking (Continuation of item 3 of first sheet)					
This International Searching Authority found multiple inventions in this international application, as follows: The invention of claims 1-9 relates to a process for producing silicon through a vapor-phase reaction of silicon tetrachloride and zinc, wherein silicon is deposited on seed crystals in a reaction furnace of 910°C or higher so as to obtain crystalline silicon. The invention of claims 10-19 relates to a process for producing silicon through a vapor-phase reaction of silicon tetrachloride and zinc, wherein silicon melts are aggregated so as to obtain molten silicon. The invention of claims 20-29 relates to a process for producing a high-purity silicon through a vapor-phase reaction of silicon tetrachloride and zinc, (continued to extra sheet) X As all required additional search fees were timely paid by the applicant, this international search report covers all searchable claims.					
of any additional fee. 3. As only some of the required additional search fees were timely paid by the applicant, this international search report covers only those claims for which fees were paid, specifically claims Nos.:					
4. No required additional search fees were timely paid by the applicant. Consequently, this international search report is restricted to the invention first mentioned in the claims; it is covered by claims Nos.:					
Remark on Protest The additional search fees were accompanied by the applicant's protest. No protest accompanied the payment of additional search fees.					

INTERNATIONAL SEARCH REPORT

International application No. PCT/JP03/11656

Continuation of Box No. II of continuation of first sheet(1)

wherein silicon is precipitated, melted and cooled to thereby obtain silicon.

The invention of claims 30-40 relates to a process wherein silicon tetrachloride and zinc are reacted with each other in an atmosphere of zinc tetrachloride, led into a retention tank of melting temperature or higher and cooled so as to effect solidification. The invention of claims 41-48 relates to a process for producing silicon, involving specified processes for producing zinc chloride and silicon tetrachloride. The invention of claims 49-68 relates to an apparatus for silicon production comprising a trap capable of collecting silicon formed by reaction and a process for producing silicon with the use of the production apparatus. The invention of claim 69 is directed to a method of reacting silicon tetrachloride with zinc wherein the reaction is conducted at a temperature lower than the melting point of silicon, while avoiding contact of the silicon with atmospheric air, thereby obtaining silicon.

It does not appear that between these inventions, there exists a technical relationship involving "special technical features".

Therefore, the requirement of unity of invention is not satisfied.

国際調査報告

国際出願番号 PCT/JP03/11656

A. 発明の風する分野の分類(国際特許分類(IPC))					
Int.Cl.'C01B 33/035					
B. 調査を行	テった分野				
	b小限資料(国際特許分類(IPC))				
T + 61 7	30.5 7 9 9 4 9 9				
Int. Cl. ' C 0 1 B 3 3 / 0 0					
最小限資料以外の資料で調査を行った分野に含まれるもの					
日本国実用新案公報 1922-1996年					
日本国公開実用新案公報 1971-2003年					
	用新案公報 1994-2003年 案登録公報 1996-2003年	•	}		
国際調査で使用した電子データベース(データベースの名称、調査に使用した用語)					
JSTPlus (JOIS)					
 C. 関連する	 5と認められる文献				
引用文献の	3と総の64で3大阪	•	関連する		
カテゴリー*	引用文献名 及び一部の箇所が関連すると	きは、その関連する箇所の表示	請求の範囲の番号		
EΧ	JP 2003-342016 A (島宗孝之)2003.1 右欄49-50行目参照(ファミリー		1-9		
PΧ	JP 2003-95633 A (蒲池豊)2003.04.03,特許請求の範囲参照(ファミリーなし)		1,8		
·X	D.A.SEIFERT , PILOT-SCALE DEVELOPM	ENT OF THE ZINC PEDICTION P	1-5, 7, 30-35,		
Λ	ROCESS FOR PRODUCTION OF HIGH-PUR	37-38, 69			
Α	SERIES , 1982 , No. 216, Vol. 78 p. 10		6, 8–29, 36,		
A	SERIES , 1902 , NO. 210, VOI. 10 p. 10	4 110	39-68		
			00 00		
□ C欄の続きにも文献が列挙されている。 □ パテントファミリーに関する別紙を参照。					
* 引用文献の	ウカテゴリー	の日の後に公表された文献			
	車のある文献ではなく、一般的技術水準を示す				
. もの	エロサム山原ナルル他かったては 一同欧山原口	出願と矛盾するものではなく、3 の理解のために引用するもの	発明の原理又は理論		
	質日前の出願または特許であるが、国際出願日 公表されたもの	「X」特に関連のある文献であって、	当該文献のみで発明		
	主張に疑義を提起する文献又は他の文献の発行	の新規性又は進歩性がないと考			
	くは他の特別な理由を確立するために引用する	「Y」特に関連のある文献であって、			
文献(理由を付す) 上の文献との、当業者にとって自明である組合せに 「O」ロ頭による開示、使用、展示等に言及する文献 よって進歩性がないと考えられるもの					
「O」ロ頭による開示、使用、展示等に言及する文献 よって進歩性がないと考えられるもの 「P」国際出願日前で、かつ優先権の主張の基礎となる出願 「&」同一パテントファミリー文献					
国際調査を完了	16. 12. 03	国際調査報告の発送日 13.01.	04		
		特許庁審査官(権限のある職員) 増山 淳子	4G 9830		
	国特許庁 (ISA/JP) 郵便番号100-8915	70 70 70 70 70 70 70 70 70 70 70 70 70 7	3		
東京都千代田区段が関三丁目4番3号		電話番号 03-3581-1101	内線 3416		